

**Amendments to the Claims:**

This listing of claims will replace all prior versions, and listings, of claims in the application.

**Listing of Claims:**

1. (currently amended) A template formed from a layered structure comprising:  
a substrate<sub>2</sub> and  
a single-phase polymer layer positioned on the substrate<sub>2</sub> [[,]]  
wherein the polymer layer comprises a textured surface, the texturing being caused by induction of stress in the polymer layer after baking of the polymer layer at a temperature below the glass transition temperature of the polymer.
2. (original) A template according to claim 1, additionally comprising a semiconductor layer positioned on the polymer layer.
3. (previously presented) A template according to claim 1, wherein the single-phase polymer is selected from polymethylglutarimide (PMGI), polymethylmethacrylate (PMMA) and photoresist AZ5214E.
4. (previously presented) A template according to claim 2, wherein the semiconductor is germanium.

5. (previously presented) A template according to claim 1, wherein the substrate comprises silicon.

6. (previously presented) A template according to claim 1, wherein the textured surface comprises parallel grooves.

7. (previously presented) A template according to claim 1, wherein the thickness of the single-phase polymer layer is 50-300 nm.

8. (previously presented) A template according to claim 2, wherein the thickness of the semiconductor layer is approximately 10 nm.

Claims 9-26: Canceled

27. (new) A template according to claim 1, wherein the textured surface has been stabilized by annealing after the induction of stress.